

Electrodeposition of Multilayered Co/Cu Nanowires

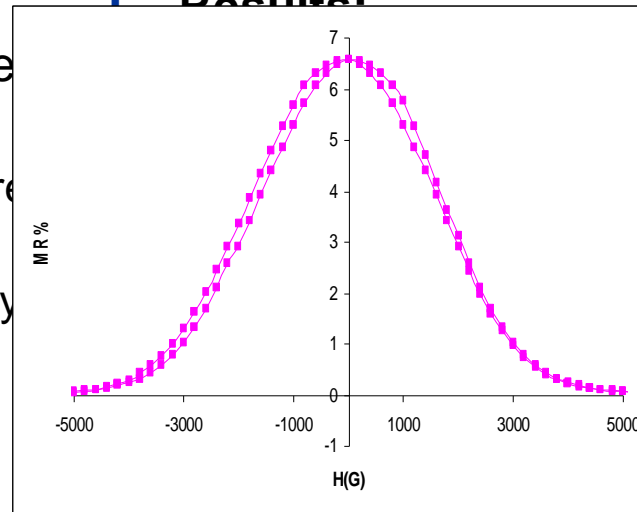
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I Motivation: Measure Giant Magnetoresistance in Multilayered Co/Cu Nanowires

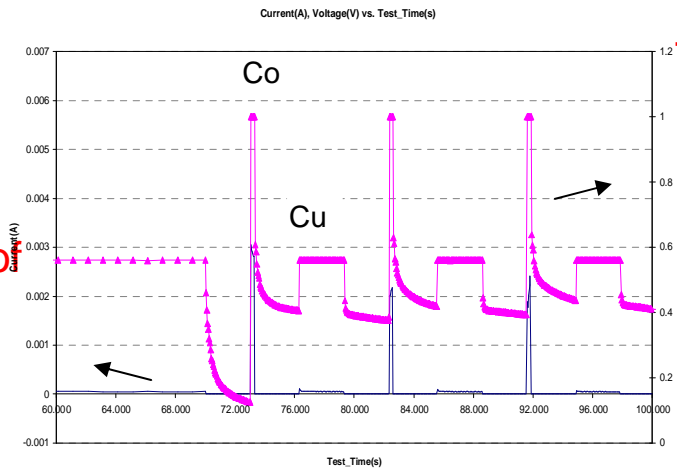
- Fabricate multilayered Co/Cu nanowires on ordered alumina template
- Control the thickness of Co and Cu layers
- Study the temperature and thickness dependence of GMR in multilayered Co/Cu nanowires

Results

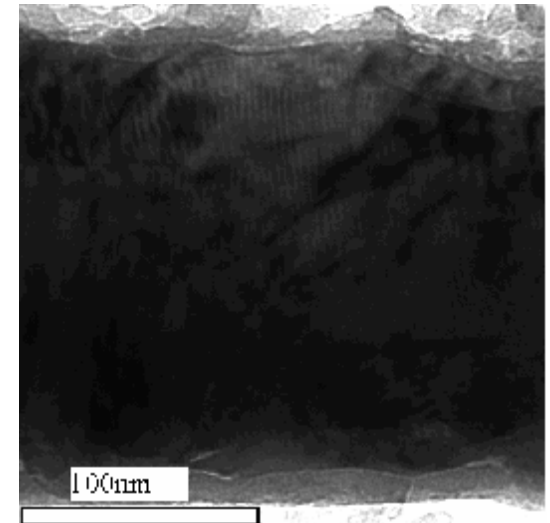


GMR of Co(5nm)/Cu(5nm) multilayered nanowire at room temperature

Electrodeposition of Co/Cu nanowires.



TEM of Co/Cu multilayered nanowire.



- P.D. McGary, L.Tan, J.Zou, B.J.H. Stadler, P. Downey, A.Flatau. Accepted to Journal of Applied Physics (Sept 2005).
- B.J.H. Stadler, N.h. Kim, L.W. Tan, J. Zou, K. Kelchner, R.K. Cobian (Invited) MRS Proceedings 16.3 (2005).